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ÍATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:

Takeyoshi SHIBASAKI, et al

SERIAL NO:

Docket No.

10/049,902

GAU:

FILED:

February 20, 2002

EXAMINER:

FOR:

AMORPHOUS FINE SILICA PARTICLE, ITS PRODUCTION PROCESS AND APPLICATION

INFORMATION DISCLOSURE STATEMENT UNDER 37 CFR 1.97

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

Applicant(s) wish to disclose the following information.

REFERENCES

- ☐ The applicant(s) wish to make of record the references listed on the attached form PTO-1449. Copies of the listed references are attached, where required, as are either statements of relevancy or any readily available English translations of pertinent portions of any non-English language references.
- A check is attached in the amount required under 37 CFR §1.17(p).

RELATED CASES

- Attached is a list of applicant's pending application(s) or issued patent(s) which may be related to the present application. A copy of the patent(s), together with a copy of the claims of the pending application(s) is attached along with PTO 1449.
- A check is attached in the amount required under 37 CFR §1.17(p).

CERTIFICATION

- ☐ Each item of information contained in this information disclosure statement was first cited in a communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of this statement.
- ☐ No item of information contained in this information disclosure statement was cited in a communication from a foreign patent office in a counterpart foreign application or, to the knowledge of the undersigned, having made reasonable inquiry, was known to any individual designated in 37 CFR §1.56(c) more than three months prior to the filing of this statement.

DEPOSIT ACCOUNT

Please charge any additional fees for the papers being filed herewith and for which no check is enclosed herewith, or credit any overpayment to deposit account number 15-0030. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

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				APPLICANT Takeyoshi SHIBASAKI, et al.			♦\
LIST OF	REFE	RENCES CITED BY A	PPLICANT				
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				February 20, 2002			
				U.S. PATENT DOCUMENTS			3
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LIST OF RELATED CASES

<u>Docket Number</u> 1129-0003-0	Serial or Patent Number 6,077,640	Filing or <u>Issue Date</u> 06/20/00	Status or <u>Patentee</u> IKOMAI, et al.
220644US0 PCT	10/088,101	05/31/02	PENDING
223746US2 PCT	10/148,212	09/05/02	PENDING
229411US0	10/326,542	12/23/02	PENDING
218781US0 PCT*	10/049,902	02/20/02	PENDING

^{*}Present Application; listed for information